



Vacuum Coating Technology Custom Systems

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General

General

The UNIVEX multi-purpose experimentation systems were developed by Oerlikon Leybold Vacuum for applications in research and development, as well as for setting up pilot production systems. Their range of applications focuses chiefly on vacuum coating technology as well as vacuum process engineering experiments.

The universal experimentation systems from Oerlikon Leybold Vacuum are

based on a modern modular concept suited for customised expansion. The high vacuum pumps are fitted horizontally at the side of the base panel, respectively the vacuum chamber.

Application and Accessories

	shift of	o ante	-350 -mft	50G	40 ^B	ersions
Applications	S Bell iar system	JL	Door system	JL	Crip	
Passive components						
Sensor technology						
Opto-electronics						
Tribology						
Soldering						
Dactyloscopy						
Glove box applications						
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Accessories / Process Components

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Products

UNIVEX 300



UNIVEX 300, typical arrangement with stainless steel bell jar and process components

Bench System with a Vacuum Bell Jar (300 mm diameter)

Typical Applications

- Vacuum coating in research and development
- Special experiments

Basic Unit

- The pump system and the electrical supply system are housed in a 19" rack cabinet
- Moreover, the 19" cabinet provides space for a vacuum gauge and a thickness measuring instrument as well as power supply units for the process components
- The basic unit may be placed on a bench top

Vacuum Chamber

- The base plate is attached to the lateral intake port of the basic unit
- Either a vacuum chamber made of stainless steel or glass may be placed on the base plate

Pump System

 The standard pumping equipment comprises a TRIVAC D 8 B twostage rotary vane pump and a TUR-BOVAC 361 turbomolecular pump

Vacuum Measurement

 Depending on the type of application, a combination vacuum gauge operating according to the cold cathode or hot cathode principle may be installed

Advantages to the User

- Modular system design
- Any kind of process component may be installed

- Process components may be retrofitted without problems
- Free access to vacuum bell jar, base plate and chamber units

Options

- Upon request, the UNIVEX 300 may be equipped with a manual lifting facility for the bell jar or also a PLC controller for process automation
- For processes in which aggressive media need to be pumped, a seal gas version of the turbomolecular pump and a rotary vane pump with a special oil filling can be supplied
- For particularly sensitive processes, a dry compressing backing pump like the SCROLLVAC SC 30 D can be used

More information on these options is available upon request.



Dimensional drawing for the UNIVEX 300 with base plate and stainless steel bell jar



Dimensional drawing for the base plate on the UNIVEX 300

Technical Data

UNIVEX 300

Stainless Steel with Viewing Window (optional: Pyrex glass)

Vacuum chamber	Base panel with bell jar fitted from the top
Diameter mm	300
Base plate	
Material	stainless steel
High vacuum connection flange DN	100 ISO-K, attached at the side
Dimensions (H x dia.) mm	60 x 350
Installation bores mm	ø 34,5 (13 x) ¹⁾
Further side flanges DN	2 x 10 ISO-KF, 1 x 40 ISO-KF ¹⁾
Vacuum bell jar	Stainless steel with viewing window (optional: Pyrex glass)
High vacuum pump	TURBOVAC 361
Nominal pumping speed for N_2 I x s ⁻¹	345
Power supply	TURBOTRONIK NT 20
Backing pump	TRIVAC D 8 B
Nominal pumping speed m ³ x h ⁻¹	9.7
Controller	Power supply with main switch slot module
Electrical connection	230 V, 50 Hz, max. 16 A ^{2), 3)}
Cooling water connection	
Hose DN 10 bar	4 to 7
Cooling water consumption, approx.	
l x min ⁻¹	1 3)
Weight, approx. kg	170 ³⁾

Ordering Information

UNIVEX 300

UNIVEX 300

upon request

1) Standard configuration, other hole patterns/flanges upon request

2) Other voltages and frequencies upon request

³⁾ Without chamber installations/process components

Options for the UNIVEX 300

Pyrex Glas Bell Jar (Vacuum Chamber)



Technical Data

1) With punched steel cover for implosion protection

Technical Data		Bell Jar, Pyrex Glas
Dimensions (H x dia.)	mm	350 x 300
Height, cylindrical section	mm	200
Seal		FPM
Weight	kg	5.6
Ordering Information	I	Bell Jar, Pyrex Glas
Bell jar, Pyrex glas		upon request ¹⁾

Dimensional drawing for the glass bell jar with implosion protection

Stainless Steel Bell Jar (Vacuum Chamber)



Technical Data Bell Jar, Stainless Steel 380 x 300 Dimensions (H x dia.) mm 300 Height, cylindrical section mm Seal FPM Weight kg 9.6 **Bell Jar, Stainless Steel Ordering Information** upon request ²⁾ Bell jar, stainless steel

Dimensional drawing for the stainless steel bell jar

²⁾ With DN 100 viewing window and 2 carrying handles; hole at the top (34.5 mm dia.)

UNIVEX 350



UNIVEX 350

Laboratory System with Cubic Vacuum Chamber and Front Door (350 mm diameter)

Typical Applications

- Vacuum coating in research and development

Pre-production trials

- Special experiments

Design

- The UNIVEX 350 consists of two separable 19" rack mount cabinets
- The process chamber and the pump system are accommodated in one cabinet
- Accommodated in the second cabinet section is the electric power supply with the PLC based system controller with graphic touchscreen. Moreover, the supply units for the process components are also accommodated in this cabinet section

Vacuum Chamber

- The base plate is attached to the base frame
- The door is equipped with a viewing window
- Bottom plate and lid are provided with installation holes
- Additional flanges at the side for pump system and process components

Pump System

 The standard pumping equipment comprises a TRIVAC D 25 B twostage rotary vane pump and a TURBOVAC 600 C turbomolecular pump

Vacuum Measurement

 Depending on the type of application, a combination vacuum gauge operating according to the cold cathode or hot cathode principle may be installed



UNIVEX 350, custom version with higher vacuum chamber and on castors



UNIVEX 350, custom version with second coating module

Advantages to the User

- Modular system design
- Freedom of installation and retrofitting of process components without problems
- Vacuum chamber with front door for highly flexible use
- Convenient access to the chamber installations
- Very simple to operate and use via programmable control
- For installation into clean-room walls
- For RF sputtering
- Pump system adapted to the individual process



Options

- A water-cooled vacuum chamber can also be supplied
- Evaporation protection plates which may be easily disassembled are available
- A water-cooled vacuum chamber can also be supplied
- Evaporation protection plates which may be easily disassembled are available
- Fitting of a second coating module with a vacuum chamber (fitted to the right of the electrical cabinet) is provided for
- For processes which develop increased quantities of gas or which require low operating pressures, the UNIVEX 350 can also be equipped with a turbomolecular pump having a higher pumping speed (TURBOVAC 1000, for example) or with cryopumps
- For processes which involve pumping of aggressive media, a barrier gas version of the turbomolecular pump and a rotary vane pump with a filling of special oil may be supplied
- For especially sensitive processes also a dry compressing vacuum pump like the ECODRY M may be used as the backing pump



Dimensional drawing for the UNIVEX 350



Dimensional drawing for the vacuum camber

Technical Data

UNIVEX 350

Vacuum chamber		
Material		Stainless steel
Dimensions		
Inside width	mm	370
Inside depth	mm	380
Inside heigth	mm	500
Connections ¹⁾		
Front side		Door with window
Rear side	DN	160 ISO-K (pump system connection), 2 x 16 ISO-KF, 2 x 40 ISO-KF
Bottom plate		15 installation holes 34.5 mm dia.
Cover plate		7 installation holes 34.5 mm dia.
Left side	DN	160 ISO-K
Right side	DN	160 ISO-K
High vacuum pump		TURBOVAC 600 C
Nominal pumping speed for N	l ₂ Ix∙s ⁻¹	560
Power supply		TURBOTRONIK NT 20
Backing pump		TRIVAC D 25 B
Nominal pumping speed	m ³ x h ⁻¹	29.5
Controller		PLC with graphic touchscreen
Required supplies		
Voltage		400 V, 3 phases + N, 50/60 Hz ²⁾
Cooling water		
Inlet pressure	bar (abs.)	4 to 7
Consumption, approx.	l x min ⁻¹	1 3)
Feed temperature	°C	15 to 25
Compressed air	bar (abs.)	4 to 7
Weight, approx.	kg	400 ³⁾

Ordering Information

UNIVEX 350

1) Standard configuration, other hole patterns/flanges upon request

²⁾ Other voltages and frequencies upon request

³⁾ Without chamber installations/process components

UNIVEX 350

upon request

Notes

UNIVEX 350 G



UNIVEX 350 G, consisting of electrical cabinet (left) and coating module (right)

Laboratory System for Glove Box Attachment with Cubic Vacuum Chamber and Front Sliding Door (350 mm diameter)

Typical Applications

- Vacuum coating in research and development
- Pre-production trials
- Special experiments

Design

- The UNIVEX 350 G consists of a coating module and a 19" rack cabinet
- Installed in the coating module is the process chamber and the pump system
- Accommodated in the cabinet is the electric power supply with the PLC based system controller with graphic touchscreen. Moreover, the supply units for the process components are also accommodated in this cabinet section

Vacuum Chamber

- The base plate is attached to the base frame
- The sliding front door is operated manually and closed pneumatically
- Bottom plate and lid are provided with installation holes
- Additional flanges at the side for pump system and process components

Pump System

 The standard pumping equipment comprises a TRIVAC D 25 B twostage rotary vane pump and a TURBOVAC 600 C turbomolecular pump

Vacuum Measurement

 Depending on the type of application, a combination vacuum gauge operating according to the cold cathode or hot cathode principle may be installed

Advantages to the User

- Intended for fitting to the rear side of a glove box
- Convenient access to the process through the glove box by means of the sliding front door
- Easy access to the chamber unit through the rear service door
- Only the sliding door is located in the glove box. All other system components can be easily accessed from the outside
- Modular system design
- Freedom of installation and retrofitting of process components without problems
- Very simple to operate and use via programmable control
- For RF sputtering
- Pump system adapted to the individual process



Options

- Easy to disassemble coating protection panels are available
- For short pumpdown times, a bypass line bypassing the high vacuum pump can be provided
- For processes producing increased amounts of gas or for low operating pressures, the UNIVEX 350 G may also be equipped with turbomolecular pumps offering a higher pumping speed (TURBOVAC 1100 C, for example) or cryogenic pumps may be specified
- For processes in which aggressive media need to be pumped, a seal gas version of the turbomolecular pump and a rotary vane pump with a special oil filling can be supplied
- For particularly sensitive processes, a dry compressing backing pump like the SCROLLVAC SC 30 D can be used

Turnkey Solutions

Upon request Oerlikon Leybold Vacuum will also arrange the delivery of turnkey solutions consisting of the UNIVEX 350 G coating system and a glove box from a single source.

More information on such systems is available upon request.



Dimensional drawing for the UNIVEX 350 G



3D view of a glove box with the UNIVEX 350 G coating module fitted to the rear

Technical Data

UNIVEX 350 G

Vacuum chamber		
Material		Stainless steel
Dimensions		
Inside width	mm	370
Inside depth	mm	380
Inside heigth	mm	500
Connections ¹⁾		
Front side		Sliding door for glove box access; manually operated and pneumatically closing
rear side		turning door for service access; manually locked
Bottom plate		15 installation holes 34.5 mm dia.
Cover plate		7 installation holes 34.5 mm dia.
Left side	DN	160 ISO-K (pump system connection), 40 ISO-KF, 16 ISO-KF
Right side	DN	40 ISO-KF, 16 ISO-KF
High vacuum pump		TURBOVAC 600 C
Nominal pumping speed for N ₂	Ix s ⁻¹	560
Power supply		TURBOTRONIK NT 20
Backing pump		TRIVAC D 25 B
Nominal pumping speed	n ³ x h ⁻¹	29.5
Controller		PLC with graphic touchscreen
Required supplies		
Voltage		400 V, 3 phases + N, 50/60 Hz ²⁾
Cooling water		
Inlet pressure ba	ar (abs.)	4 to 7
Consumption, approx.	x min ⁻¹	1 ³⁾
Feed temperature	°C	15 to 25
Compressed air ba	ar (abs.)	4 to 7
Weight, approx.	kg	350 ³⁾

Ordering Information

UNIVEX 350 G

UNIVEX 350 G

upon request

1)	Standard configuration, other hole patterns/flanges/viewing windows upon request
2)	Other voltages and frequencies upon request
~	

³⁾ Applies only to the coating module, without chamber units/process components

Notes

UNIVEX 450 B





UNIVEX 450 B with water-cooled vacuum chamber (option)

Laboratory System with Cubic Vacuum Chamber and Front Door (500 mm diameter)

Typical Applications

- Vacuum coating in research and development
- Pre-production trials
- Special experiments

Design

- The UNIVEX 450 B consists of two separable 19" cabinet sections
- Accommodated in one cabinet section is the process chamber and the pump system
- Accommodated in the second cabinet section is the electric power supply with the PLC based system controller with graphic touchscreen. Moreover, the supply units for the process components are also accommodated in this cabinet section

Vacuum Chamber

- The base plate is attached to the base frame

load lock chamber (option)

- The door is equipped with a viewing window
- Bottom plate and lid are provided with installation holes
- Additional flanges at the side for pump system and process components

Pump System

 The standard pumping equipment comprises a TRIVAC D 65 B twostage rotary vane pump and a TURBOVAC 1100 C turbomolecular pump

Vacuum Measurement

 Depending on the type of application, a combination vacuum gauge operating according to the cold cathode or hot cathode principle may be installed

Advantages to the User

- Modular system design
- Freedom of installation and retrofitting of process components without problems
- Vacuum chamber with door
- Convenient access to the chamber installations
- Very simple to operate and use via programmable control
- Suited for being installed in a clean room wall
- For RF sputtering
- Pump system adapted to the individual process



Options

- The chamber can also be delivered in a water-cooled version
- Easy to disassemble coating protection panels are available
- For short pumpdown times, a bypass line bypassing the high vacuum pump can be provided
- Fitting of a second coating module with a vacuum chamber (fitted to the right of the electrical cabinet) is provided for
- For processes producing increased amounts of gas or for low operating pressures, the UNIVEX 450 B may also be equipped with turbomolecular pumps offering a higher pumping speed (TURBOVAC T1600, for example) or cryogenic pumps may be specified
- For processes in which aggressive media need to be pumped, a seal gas version of the turbomolecular pump and a rotary vane pump with a special oil filling can be supplied
- For particularly sensitive processes, a dry compressing backing pump like the SCROLLVAC SC 30 D can be used





and installation bores can be adapted according to customer specifications!

Dimensional drawing for the vacuum camber

Dimensional drawing for the UNIVEX 450 B

Technical Data

UNIVEX 450 B

Vacuum chamber		
Material		Stainless steel
Dimensions		
Inside width	mm	500
Inside depth	mm	500
Inside heigth	mm	650
Connections ¹⁾		
Front side		Door with window
Rear side	DN	250 ISO-K (pump system connection), 4 x 16 ISO-KF, 2 x 40 ISO-KF
Bottom plate		20 installation holes 34.5 mm dia.
Cover plate		10 installation holes 34.5 mm dia.
Left side	DN	250 ISO-K
Right side	DN	250 ISO-K
High vacuum pump		TURBOVAC 1100 C
Nominal pumping speed for N ₂	Ix s ⁻¹	1050
Power supply		TURBOTRONIK NT 20
Backing pump		TRIVAC D 25 B
Nominal pumping speed	m ³ x h ⁻¹	29.5
Controller		PLC with graphic touchscreen
Required supplies		
Voltage		400 V, 3 phases + N, 50/60 Hz ²⁾
Cooling water		
Inlet pressure b	ar (abs.)	4 to 7
Consumption, approx.	x min ⁻¹	1 3)
Feed temperature	°C	15 to 25
Compressed air b	ar (abs.)	4 to 7
Weight, approx.	kg	500 ³⁾

Ordering Information

UNIVEX 450 B

upon request

UNIVEX 450 B

¹⁾ Standard configuration, other flanges/hole patterns/viewing windows upon request

 $^{\mbox{2}\mbox{)}}$ Other voltages and frequencies upon request

³⁾ Applies only to the basic unit without coating equipment

Notes

UNIVEX 450 for Dactyloscopy



UNIVEX 450 for dactyloscopy

Dactyloscopy is a term from the area of criminal investigation meaning: "Identification of a person through his fingerprints". Depending on the material of the part which was touched, different methods are used to render the fingerprints visible.

In the case of materials like plastic shopping bags, for example, foils, handlebars etc. evaporation methods have been found to be most useful.

The method itself utilises the effect well known from normal evaporation processes where the evaporated material will adhere better (and thicker) on the skin material (water, amino acids, fat and alike) deposited by the finger compared to the surrounding untouched material.

An optimum contrast is attained by selecting a suitable evaporation material, usually gold or zinc.

Benefits of this method

- No "smearing" of existing traces compared to conventional methods
- Large surface areas (up to 80 x 40 cm max.) carrying fingerprints can be checked completely in one pass
- The time needed for one pass is only about 10 minutes (depending on the material carrying the fingerprints)
- Good contrast also in the case of multicolour surfaces
- Fixation of the deposited material with the traces is easy – the results may be well documented (can be photographed)
- The carrier of the fingerprints is not destroyed

UNIVEX 450 C



For special applications we can also supply cluster systems based on the UNIVEX concept. These clusters are equipped according to customers requirements and incorporate separate processing and load lock and transfer chambers.

UNIVEX 450 C with coating module and electrical cabinet (example photograph). The coating module consists of two process chambers (left and right) as well as the loadlock and transfer chamber in between

Test Systems with a Vacuum Chamber



We can also supply vacuum chambers with custom pump systems for testing of various components.

Test system with a 700 mm dia chamber

Accessories

Standard Accessories for UNIVEX Systems

Blank-Off Screw Fitting

For 34.5 mm dia. hole.



Technical Data		Blank-Off Screw Fitting
Material		Stainless steel
Seal		FPM
Weight	kg	0.1
Ordering Information		Blank-Off Screw Fitting
Blank-off screw fitting		Part No. 030 40

Blank-off screw fitting

PS 113 A Safety Switch

For safety interlock arrangements in connection with the UNIVEX system controller, respectively optionally connected power supply equipment (for sputtering, electron beam evaporation or vacuum etching, for example).



PS 113 A Safety Switch

Technical Data

Switching pressure mba	approx. 6 below atmospheric pressure
Return switching pressure mba	a 6 below atmospheric pressure
Switching inaccuracy mba	r 26
Max. permissible operating pressure (abs.) mba	r 2000
Storage temperature range °C	-25 to +85
Nominal temperature range °C	0 to 85
Switching contact	Changeover contacts, gold-plated, for prog. controls
Contact life	> 10 ⁵ switching cycles
Switching capacity	100 mA / 24 V AC 30 mA / 24 V DC
Electrical connection	6.3 mm flat plug
Vacuum connection DN	I 16 ISO-KF
Materials in contact with the medium	Stainless steel 1.4305, 1.4310, Stainless steel 1.4300 PTFE coated
Protection class IF	44

Ordering Information

Low pressure safety switch PS 113 A, DN 16 ISO-KF; complete with 3 m long cable

Variable Leak Valve with **Isolation Valve**

For manually controlled admission of gas in connection with plasma processes (sputtering, etching and glow discharge cleaning).

Technical Data		
Gas admission rate q	m	

Gas admission rate q_L	mbar x I x s ⁻¹	5 x 10 ⁻⁶ to 1 x 10 ³
Connection flange	DN	16 ISO-KF
Ordering Information		Variable Leak Valve with Isolation Valve
Variable leak valve with isolation valve		Part No. 215 010

(see also Product Section C14 "Vacuum Valves")

Safety Switch

Safety Switch

Part No. 230 011

Variable Leak Valve with Isolation Valve

Gas Flow Controller (MFC)

For controlled admission of gas in connection with automated plasma processes (sputtering, etching, glow discharge cleaning). Intended to be remotely controlled by the customer's PC or PLC, i.e. a separate MFC controller unit is not included in the delivery.

Electromotively Operated Vapor Source Shutter

For covering the source during thermal or electron beam evaporation. With gear motor and shutter panel; can be fitted to the inside sections of the chamber.

6-Way Measurement Feedthroughs

For connection of the vapor source shutter; for 34.5 mm holes, plug-in soldered contact on the inside.



6-way measurement feedthrough

Control Cable, 6-Way

For connection between measurement feedthrough and power supply unit for the vapor source shutter, complete with connection plugs.

Interlocking Kit

For providing touch protection against high-voltage carrying parts within the vacuum chamber. The safety contact must be connected to the interlock input at the high-voltage power supply unit thereby ensuring that the equipment can be enabled only while the chamber door is closed.

Technical Data

	upon request
	Gas Flow controller
v	0 - 5 analog
V DC	24
sccm	selectable between 10 and 500
	sccm V DC V

Gas Flow controller

Technical Data	Vapor Source Shutter	
Control voltage	V DC	24 (pulses per second)
Dimensions of the shutter panel	mm	different, for example 42 x 42 or 100 mm dia.
Weight	kg	0.2
Ordering Information		Vapor Source Shutter
Electromotively operated vapor source shutter		upon request

Technical Data		Measurement Feedthrough	
Rating per conductor	v	max. 700	
	Α	16	
Seal		FPM	
Weight	kg	0.3	
Ordering Information		Measurement Feedthrough	
6-way measurement feedthrough		upon request	

Technical Data		Control Cable
Lenght	m	3
Weight	kg	0.2
Ordering Information		Control Cable
6-way control cable		upon request
Technical Data		Interlocking Kit
Mechanical closing contact		Safety door switch
Electrical closing contact		floating
Ordering Information		Interlocking Kit
Interlocking kit for		

UNIVEX vacuum chamber

upon request

Components for Thermal Evaporation of High Melting Point Materials (metals)

Single Thermal Evaporator

Consisting of two water-cooled high voltage feedthroughs with terminal blocks for 34.5 mm dia. holes.



Single thermal evaporator

Dual Thermal Evaporator

Consisting of three water-cooled high voltage feedthroughs with terminal blocks for 34.5 mm dia. holes.



Dual thermal evaporator

Power Supply Cables

For single and dual thermal evaporators, equipped with terminals and clamping pieces.

Technical Data		Single Thermal Evaporator	
Rating per conductor	v	max. 100	
	Α	500	
Seals		FPM	
Water connection	mm	Hose 4/6 dia.2.5	
Weight	kg		
Ordering Information		Single Thermal Evaporator	
Single thermal evaporator		upon request	

Technical Data	Dual Thermal Evaporator
Rating per conductor	V max. 100
	A 500
Seals	FPM
Water connection m	m Hose 4/6 dia.
Weight	<g< b=""> 3.9</g<>
Ordering Information	Dual Thermal Evaporator
Dual thermal evaporator	upon request

Technical Data		Power Supply Cable
Length	m	2 1)
Rating	V	max. 100
	Α	500
Cross section	mm ²	120
Weight	kg	3.5
Ordering Information	'	Power Supply Cable
Power supply cable		upon request ²⁾

1) Standard length. Other lengths can be specified

²⁾ For the single thermal evaporator, two supply lines are required. For the dual thermal evaporator, three supply lines are required

AS 053 Power Supply Unit

For supplying thermal evaporators and one solenoid-actuated source shutter. With LCD display for current read out; with membrane key pad.



AS 053 power supply unit

AS 053/2 Power Supply Unit

For supplying power to two thermal evaporators with vapor source shutters. With LCD display for current read out; with membrane key pad.

Technical Data

Power Supply Unit

Remote control unit for controlling the evaporation power (0 to 10 V) Remote control for the shutter
1 x evaporator output, 5 V, 400 A ma can be rewired to 10 V, 200 A max 1 x shutter output, 24 V DC, 1 s pulse
1/2 19" rack module, 3 HU 400 deep
n

AS 053 power supply unit

Technical Data	Power Supply Unit
Cabinet	19" rack module, 3 HU
mm	a 400 deep
Outputs	2 x evaporator output, 5 V, 400 A max. can be rewired to 10 V, 200 A max. 2 x shutter output, 24 V DC,
	1 s pulse
Inputs	Remote control unit for controlling the
	evaporation power (0 to 10 V)
	Remote control for the shutter
	Switchover evaporator 1 / 2
Main power supply	230 V, 50/60 Hz, 10 A
Weight kg	30
Ordering Information	Power Supply Unit
AS 053/2 power supply unit	upon request

Components for Thermal Evaporation of Low Melting Point (organic) Materials

For the purpose of evaporating temperature sensitive materials, commonly of an organic nature, Oerlikon Leybold Vacuum is offering special organic material evaporators. These ensure a coating process at precisely controlled evaporation temperatures which typically range between 200 °C and 400 °C. For installation within the UNIVEX systems, Oerlikon Leybold Vacuum supplies organic material evaporators as a complete package, consisting of evaporator source, automatic shutter, rotary vacuum feed through and 19" rack mount controller.

Components for Electron-Beam Evaporation

Various models of electron-beam evaporators and power supplies are available for installation in the UNIVEX systems.

Electron-Beam Evaporator

The selection of a suitable electron beam evaporator will chiefly depend on the amount of available space, the desired evaporation rate and the film thickness as well as the number and type of materials which need to be evaporated. Single crucible as well as rotatable multi-crucible evaporators are available.

Power Supplies

The power supply unit for the individual electron beam evaporators is selected depending on the maximum evaporation power which is required, as well as the demanded properties for X/Y beam deflection. Models with output power ratings ranging from 3 kW to 10 kW are available.

As a rule, the maximum output power of the power supply may not exceed the maximum permissible power specified for the evaporator.

Safety Regulations for Electron-Beam Evaporator Applications

When installing electron beam evaporators within the UNIVEX 300, only the stainless steel bell jar must be used. Moreover, a safety interlocking system will be necessary for all UNIVEX types. For the UNIVEX 300 a separate interlocking kit is available; in the case of the UNIVEX 350 and 450 B this kit is already included.

As further safety means a water flow monitor is required for each electronbeam evaporation unit so as to ensure intensive cooling of the electron-beam evaporator.

This water flow monitor is included in the delivery of a UNIVEX system equipped with an electron beam evaporator.

Upon request we shall be pleased to provide an offer which specifically matches the requirements of your application.

Components for Sputtering

DC Sputtering

Widely differing DC sputtering sources may be fitted within all UNIVEX systems. Their selection will depend on the size of the substrate, the required target material and the available installation space. Circular planar sputtering sources of 50 mm to 200 mm in diameter as well as various rectangular sources are available. The power supply units (providing an output power between 500 W and 3 kW) may be installed within the UNIVEX 19" electrical cabinets.

DC sputtering equipment is suited for all UNIVEX systems.

RF Sputtering

Widely differing RF sputtering sources may be fitted within all UNIVEX systems (exception: UNIVEX 300). Their selection will depend on the size of the substrate, the required target material and the available installation space. Circular planar sputtering sources of 50 mm to 200 mm in diameter as well as various rectangular sources together with the necessary RF matching components are available. The power supply units (providing an output power between 150 W and 1.5 kW) may be installed within the UNIVEX systems.

Gas Inlet

Sputtering sources can only be operated with gas admission. For this, manually operated variable leak valves up to automatically controlled mass flow controllers are available.

Throttling the Pumping Speed

In order to protect the high vacuum pump against the high process pressure present during plasma operation, and to reduce process gas consumption, the UNIVEX systems are generally equipped with high vacuum gate valves having three positions which are fitted between chamber and high vacuum pump.

Safety Regulations in Connection with Sputtering Applications

When installing electron beam evaporators within the UNIVEX 300, only the stainless steel bell jar must be used. Moreover, a safety interlocking system will be necessary for all UNIVEX types. For the UNIVEX 300 a separate interlocking kit is available; in the case of the UNIVEX 350 and 450 B this kit is already included.

As further safety means a water flow monitor is required for each electronbeam evaporation unit so as to ensure intensive cooling of the electron-beam evaporator.

This water flow monitor is included in the delivery of a UNIVEX system equipped with an electron beam evaporator.

Upon request we shall be pleased to provide an offer which specifically matches the requirements of your application.

Components for Glow Discharge Cleaning

With glow discharge electrode, high voltage feedthrough for 34.5 mm dia. hole and connection cable for fitting to the central rotary feedthrough.



Glow discharge assembly with high voltage feedthrough and connection cable

C 2000 High Voltage **Power Supply Unit**

For supplying the glow discharge assembly.



C 2000 high voltage power supply unit

Gas Admission

Operation of the glow discharge cleaning facility is only possible by admitting gas. For this, manually operated dosing valves up to automatically controlled mass flow controllers offer all possibilities.

Technical Data

Electrode material		Aluminum
Insulation		Ceramics
Max. ratings	V	2000
	mA	65
Sealing material of the		
high voltage feedthrough		FPM
Length of the connection cable	m	2
Weight	kq	1

Ordering Information

Glow discharge assembly for UNIVEX 300, 350 and 350 G for UNIVEX 450 B

Glow Discharge Assembly

Glow Discharge Assembly

upon request upon request

Technical Data	High Voltage Power Supply Unit
Cabinet	19" rack module, 3 HU
Output V mA	max. 2000 max. 65
Electrical connection	230 V, 50/60 Hz, 150 VA
Remote control and locking input	included

Remote control and locking input

Ordering Information

C 2000 high voltage power supply unit

High Voltage Power Supply Unit upon request

Throttling the Pumping Speed

In order to protect the high vacuum pump against the high process pressure present during plasma operation, and reduce process gas consumption, the UNIVEX systems are generally equipped with high vacuum gate valves having three positions which are fitted between chamber and high vacuum pump.

Components for Film Thickness Measurements

Various thin film thickness measuring instruments may be installed in the UNIVEX units.

The selection depends on the demanded measurements tasks and the required degree of automation. As standard, oscillating crystal systems are used. These may consist of one or several sensing heads with or without shutter, and upon request are available also for UHV operation (i.e. are suitable for degassing).



These are driven either by a monitor (allowing only the measurement of deposition rate and film thickness) or by a controller (allowing besides measurement of the film parameters also to control the deposition rate).

Upon request we shall be pleased to provide an offer which specifically matches the requirements of your application.





Substrate Manipulation Solutions

Substrate Rotation

In order to improve the film properties in connection with deposition processes in a vacuum, a rotary movement of the substrates will often be necessary.

For this reason Oerlikon Leybold Vacuum is offering for the UNIVEX product family a broad spectrum of possible solutions. These begin with a simple manually operated rotatable axle and end with speed controlled planetary gears. Moreover, there exists the possibility of linking the rotary movement to additional features like heating, cooling or bias. Depending on the number of substrates and their dimensions as well as the temperature requirements, a check of the specific circumstances will be necessary in each case.

More information on this is available upon request.



Rotatable, temperature controlled substrate holder with substrate shutter

Substrate Holding

For mounting the substrate within the chamber, Oerlikon Leybold Vacuum offers vacuum substrate holders manufactured according to customer's specifications.



Planetary gear

Substrate Heating

For temperature controlled heating of substrates, Oerlikon Leybold Vacuum offers different processes (resistance heaters, quartz lamp heaters etc., for example). Depending on the size of the substrate and the temperature range, we are prepared to offer a customised heating solution.

Substrate Cooling

Sensitive substrates or substrate masks require intensive cooling while the coating process is in progress. For this, Oerlikon Leybold Vacuum delivers substrate holders for different temperature ranges (cold water, liquid nitrogen or special fluids).

Substrate Bias

For the purpose of cleaning substrates before coating them or for improving the adhesive properties during the coating process, RF or DC biasing of the substrates can provide the required advantage. For this, Oerlikon Leybold Vacuum can supply insulated substrate mounts with or without the corresponding supply units.

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